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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/775,748	02/10/2004	Klaus Goller	1890-0054	8728
	7590 04/05/2007		EXAM	INER
Maginot, Moore & Beck LLP Chase Tower			KALAM, ABUL	
Suite 3250 111 Monument Circle		ART UNIT	PAPER NUMBER	
Indianapolis, IN			2814	
SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
2 MO	NITUS	04/05/2007	DADED	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

			~X				
	Application No.	Applicant(s)					
	10/775,748	GOLLER ET AL.					
Office Action Summary	Examiner	Art Unit					
	Abul Kalam	2814					
The MAILING DATE of this communication Period for Reply	appears on the cover sheet w	ith the correspondence address					
A SHORTENED STATUTORY PERIOD FOR RE WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory per - Failure to reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the mearned patent term adjustment. See 37 CFR 1.704(b).	C DATE OF THIS COMMUNI R 1.136(a). In no event, however, may a riod will apply and will expire SIX (6) MOI atute, cause the application to become A	CATION. reply be timely filed NTHS from the mailing date of this communication BANDONED (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on 2	8 December 2006.						
	•						
•	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice unde	er <i>Ex parte Quayle</i> , 1935 C.[D. 11, 453 O.G. 213.					
Disposition of Claims							
4)⊠ Claim(s) <u>12-29</u> is/are pending in the applica	ation.						
4a) Of the above claim(s) is/are without							
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>12-29</u> is/are rejected.							
7) .Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction an	d/or election requirement.						
Application Papers							
9)☐ The specification is objected to by the Exam	niner.						
10)⊠ The drawing(s) filed on 10 February 2004 is	s/are: a)⊠ accepted or b)□	objected to by the Examiner.					
Applicant may not request that any objection to	the drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the cor							
11)☐ The oath or declaration is objected to by the	Examiner. Note the attache	d Office Action or form PTO-152	2.				
Priority under 35 U.S.C. § 119	•						
12)⊠ Acknowledgment is made of a claim for fore a)⊠ All b)□ Some * c)□ None of:	eign priority under 35 U.S.C.	§ 119(a)-(d) or (f).					
 Certified copies of the priority docum 							
Certified copies of the priority docum			٠				
3. Copies of the certified copies of the p		n received in this National Stage	:				
application from the International But		6					
* See the attached detailed Office action for a	list of the certified copies no	received.					
Attachment(s)							
1) Notice of References Cited (PTO-892)	·	Summary (PTO-413) (s)/Mail Date					
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB Paper No(s)/Mail Date 	'	Informal Patent Application (PTO-152)					

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DETAILED ACTION

Status of Application

1. In the amendments filed on filed on December 28, 2006, claim 12 was amended, and new claims 21-29 were added. Thus, claims 12-29 are currently pending in the application.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 12, 14-17 and 19-21, 23-26, 28 and 29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Pasch et al. (US 6,239,491; previously cited) in view of Shields et al. (US 6,087,724; previously cited).

With respect to claims 12 and 21, Pasch teaches (FIG. 3) an arrangement for contacting terminals of a substrate (2) comprising:

a substrate surface, a first terminal (10) having a first terminal surface, and a second terminal (14) having a second terminal surface, the first terminal surface being located at a shorter distance from the substrate surface than the second terminal surface (FIG. 3), the arrangement comprising:

a first insulating layer (130) on the substrate surface, having an insulation-layer surface being located at a longer distance from the substrate (2) surface than the

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second terminal (14) surface, wherein a part of said first insulating layer is arranged between the first and the second terminal (FIG. 3).

a second insulating layer (150) arranged on the first insulting layer (130) (FIG. 3); wherein the first insulating layer (130) has a contact via (132) which extends from the insulation-layer surface to the first terminal (10) surface and is filled with a first conductive material ("tungsten") (FIG. 3; col. 7, Ins. 42-46);

wherein the second insulating layer (150) has a first recess (152), the first recess penetrating the second insulating layer and extending to the first conductive material (FIG. 3) (FIG. 3; col. 7, Ins. 55-67); and

wherein a second recess (134, 154) extends to the second terminal surface (14) through the first and second insulating layers (130, 150), and is filled with a third conductive material (FIG. 3; col. 7, Ins. 42-67).

Thus, **Pasch** teaches all the limitations of the claims, as set forth above, with the exception of disclosing: wherein the first recess extends into the first insulating layer and is filled with a second conductive material, such that the second conductive material contacts the first conductive material on a top surface and on a portion of a side surface thereof.

However, **Shields** teaches (**FIG. 7**) an arrangement for contacting terminals on a substrate wherein a first recess (**62**), penetrating the second insulating layer (**65**) and extending to the first conductive material (**61A**) and into the first insulating layer (**63**), is filled with a second conductive material (**66**; **col. 6**, **Ins. 55-59**), such that the second conductive material contacts the first conductive material (**61A**) on a top surface (**161A**)

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and on a portion of a side surface (261A) thereof (col. 6, Ins. 15-65). Shield's invention is applicable to the production of various types of semiconductor devices, which exhibit high speed characteristics and improved reliability (col. 7, Ins. 26-38).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention, to modify the structure of **Pasch** with the teaching of **Shields**, for the well known purpose of forming low resistance vias, which improves the reliability and performance of interconnection structures in semiconductor devices.

Regarding the limitations of "integrally-formed" in claim 12, and "a single step of filling," in claim 21, both limitations are product by process limitations and thereby given no patentable weight. Note that a "product by process" claim is directed to the product per se, no matter how actually made. *In re Thorpe et al.*, 227 USPQ 964, (CAFC, 1985) and the related case law cited therein which makes it clear that it is the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. As stated in Thorpe:

Even though product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. *In re Brown*, 459 F.2d 531, 535, 173 USPQ 685, 688 (CCPA 1972); *In re Pilkington*, 411 F.2d 1345, 1348, 162 USPQ 145, 147 (CCPA 1969); *Buono v. Yankee Maid Dress Corp.*, 77 F.2d 274, 279, 26 USPQ 57, 61 (2d. Cir. 1935);

Note that Applicant has burden of proof in such cases as the above case law makes it clear.

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Furthermore, even if the limitations of "integrally-formed" and "single step of filling" were given patentable weight, the limitation of integrally-formed would still have been obvious since it has been held that forming in one piece of an article which has formerly been formed in two pieces and put together involves only routine skill in the art, *Howard v. Detroit Stove Works*, 150 U.S. 164 (1893). Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to integrally form the third conductive material of Pasch because the same effects of providing electrical contacts would result.

With respect to **claims 14 and 23**, **Pasch** teaches wherein the first terminal **(10)** is one of a source terminal and a drain terminal, and the second terminal is a gate terminal **(14)** of a field-effect transistor **(col. 7, Ins. 30-33)**.

With respect to claims 15 and 24, Pasch teaches wherein the first terminal (10) is one of a source terminal and a drain terminal of a field-effect transistor (col. 7, Ins. 30-33).

With respect to claims 16, 17, 25 and 26, Pasch teaches wherein a the first conductive material is tungsten (col. 7, Ins. 42-46).

With respect to claims 19 and 28, Pasch teaches (FIG. 3) wherein the second conductive material is conductively connected (via 152) to first conductive material and forms a first contact terminal, and wherein the third conductive material is conductively connected (vias 154, 134) to the second terminal (14) and forms a second contact terminal (col. 7, Ins. 42-67).

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3. Claims 13, 18, 22 and 27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Pasch et al. ('491; previously cited) and Shields et al. (US '724; previously cited), as applied above to claims 12 and 21, respectively, and further in view of Broekaart et al. (US 2001/0046784; previously cited).

With respect to claims 13 and 22, Pasch and Shields teaches all the limitations of the claim, as set forth above in claims 12 and 21, respectively, with the exception of disclosing:

The first terminal is one of a base terminal and a collector terminal, and the second terminal is an emitter terminal, arranged on a stack, of a bipolar transistor.

However, **Broekaart** teaches (**FIG. 1**) an arrangement for contacting terminals (3, 4, 5) of a substrate (1), wherein the first terminal is one of a base terminal and the second terminal is an emitter terminal, arranged on a stack, of a bipolar transistor (**pg. 1**, [0015]).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the structure of **Pasch and Shields** with the teaching of **Broekaart**, because applying an interconnection structure to semiconductor devices such as MOSFET's or bipolar transistors would have been considered a mere substitution (**pg. 1, [0015]**) of art recognized equivalent devices (MPEP 2144.06).

Substitution of equivalents requires no express motivation as long as the prior art recognizes the equivalency. *In re Fount* 213 USPQ 532 (CCPA 1982); *In re Siebentritt*

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152 USPQ 618 (CCPA 1967); Graver Tank & Mfg. Co. Inc. v. Lindle Air Products Co. 85 USPQ 328 (USSC 1950).

With respect to **claims 18 and 27**, **Pasch and Shields** teaches all the limitations of the claim, as set forth above in claims 12 and 21, respectively, with the exception of disclosing:

wherein at least one of the second and third conductive materials is copper.

However, **Broekaart** teaches (**FIG. 1**) an arrangement for contacting terminals (3, 4, 5) of a substrate (1), wherein the second conductive material (18) comprises copper (**pg. 3**, [0024]).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the structure of **Pasch and Shields** with the teaching of **Broekaart**, because substitution of art recognized equivalent materials, such as copper and tungsten (pg. 3, [0024]), which are well known conductive materials used to fill vias, would have been obvious to one of ordinary skill in the art of semiconductor devices (MPEP 2144.06).

Substitution of equivalents requires no express motivation as long as the prior art recognizes the equivalency. *In re Fount* 213 USPQ 532 (CCPA 1982); *In re Siebentritt* 152 USPQ 618 (CCPA 1967); *Graver Tank & Mfg. Co. Inc. v. Lindle Air Products Co.* 85 USPQ 328 (USSC 1950).

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Response to Arguments

4. Applicant's arguments with respect to claims 12-29, filed on December 28, 2006, have been considered but are not persuasive.

Applicant argues that the Pasch reference does not teach the limitation of "an integrally formed third conductive material," recited in claim 12, and the limitation of "wherein the third conductive material is formed in a single step of filling," recited in claim 21. These arguments are not persuasive because the limitations are considered product by process limitations, which are not given patentable weight.

Note that a "product by process" claim is directed to the product per se, no matter how actually made. *In re Thorpe et al.*, 227 USPQ 964, (CAFC, 1985) and the related case law cited therein which makes it clear that it is the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. As stated in Thorpe:

Even though product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. *In re Brown*, 459 F.2d 531, 535, 173 USPQ 685, 688 (CCPA 1972); *In re Pilkington*, 411 F.2d 1345, 1348, 162 USPQ 145, 147 (CCPA 1969); *Buono v. Yankee Maid Dress Corp.*, 77 F.2d 274, 279, 26 USPQ 57, 61 (2d. Cir. 1935);

Note that Applicant has burden of proof in such cases as the above case law makes it clear.

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Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Abul Kalam whose telephone number is 571-272-8346.

The examiner can normally be reached on Monday - Friday, 9 AM - 5 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M. Fahmy can be reached on 571-272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

PHAT X. CAO PRIMARY EXAMINER

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